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Electronic Version v1.1

Attorney Docket Number:

NAUP0470USA1

Stylesheet Version v1.1.0

Title of Invention	CLEANING COMPOSITION AND METHOD OF WASHING A SILICON WAFER
Application Number	
Date :	
First Named Applica	nt: Jeng-Wei Yang
Confirmation Number	r:

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Documents being submitted: Files NAUP0470_1_A1-usfees.xml us-fee-sheet us-fee-sheet.xsl us-fee-sheet.dtd NAUP0470_1_A1-usrequ.xml us-request us-request.dtd us-request.xsl NAUP0470_1_A1ASS1.tif us-declaration NAUP0470_1_A1ASS2.tif us-declaration us-declaration NAUP0470_1_A1DEC1.tif NAUP0470 1 A1DEC2.tif us-declaration NAUP0470-1-trans.xml application-body us-application-body.xsl application-body.dtd wipo.ent mathml2.dtd mathml2-qname-1.mod isoamsa.ent isoamsb.ent isoamsc.ent isoamsn.ent isoamso.ent isoamsr.ent isogrk3.ent isomfrk.ent isomopf.ent isomscr.ent isotech.ent isobox.ent isocyr1.ent isocyr2.ent isodia.ent isolat1.ent isolat2.ent isonum.ent isopub.ent mmlextra.ent mmlalias.ent soextblx.dtd 01.TIF Naup0470usa1-01.TIF Comments